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# Growth and characterization of Sb<sub>2</sub>Se<sub>3</sub> thin films for solar cells

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#### ABSTRACT

The growth of antimony selenide ( $Sb_2Se_3$ ) thin films the first time by atmospheric pressure chemical molecular beam deposition (CMBD) method has been reported. The morphological and structural properties of the films were studied as a function of the hydrogen flow rate at different substrate temperature. Experimental data indicate that  $Sb_2Se_3$  films grown as Se-rich at low hydrogen flow rate and the samples have almost amorphous structure. In contrast, at higher hydrogen flow rate, the films have Sb-rich composition and polycrystalline structure. Interestingly, transition from amorphous to polycrystalline structure is depend on the flow rate of the transport gas, while surface morphology affected by the substrate temperature. Electrical and optical measurements revealed that polycrystalline films have p-type conductivity and optical bandgap of 1.1 eV with high absorption coefficient of  $10^5$  cm $^{-1}$ . These results showed that the CMBD grown films can be used as absorber layer for fabrication of thin film solar cells.

#### 1. Introduction

Power generation by using cost effective and ecologically friendly photovoltaic (PV) materials is one of the key factors for development of sustainable renewable energy sector (Polman et al., 2016). Currently, solar cells based on silicon (Si), CdTe and Cu(In,Ga)Se2 have reached power conversion efficiency (PCE) of > 20% and became leading materials in the world PV market (Green et al., 2017; Jackson et al., 2016; Yoshikawa et al., 2017). However, high production cost of Si wafers. high price of Ga and In elements and toxicity issues of Cd are main limitations for PV power generation entering to multi-terawatt regime (Guha, 2017; Zakutayev, 2017). Hence, novel material systems consisting of non-toxic and earth-abundant elements have emerged. In the last decade, several compounds including metal sulphides and selenides such as Cu<sub>2</sub>ZnSnSe<sub>4</sub> (Hartnauer et al., 2016), Cu<sub>2</sub>SnS<sub>3</sub> (Chantana et al., 2017) CuSbS<sub>2</sub>, (Whittles et al., 2017), SnSe (Razykov et al., 2018) and Sb<sub>2</sub>Se<sub>3</sub> have been explored as an alternative and promising photovoltaic absorbers (Guha, 2017). Among them, antimony selenide (Sb<sub>2</sub>Se<sub>3</sub>) has emerged as a very suitable photovoltaic absorber material due to its excellent electro-optical properties (Sun et al., 2016). For example, Sb<sub>2</sub>Se<sub>3</sub> has an optical bandgap of about 1.1 eV, high absorption coefficient ( $> 10^5 \, \text{cm}^{-1}$ ) and rather simple composition, i.e. compared to Cu(In,Ge)Se<sub>2</sub> thin film solar cells (Chen et al., 2015; Bajpeyee, 2012). Furthermore, research efforts on Sb<sub>2</sub>Se<sub>3</sub> based thin film solar cells have already yielded with measurable conversion efficiency of above 7.5% over the past 3-4 years (Choi et al., 2014; Li et.al., 2018; Tiwari et al.,

2018; Wen et al., 2018; Yuan et al., 2016). Since, the  $Sb_2Se_3$  layer is the key material in  $Sb_2Se_3$  based thin film solar cells, the crystalline quality of the film is crucial. In literature,  $Sb_2Se_3$  thin films have been reported which were deposited using various growth methods, e.g. thermal evaporation (Liu et al., 2014), chemical bath deposition (Kulkarni et.al., 2015), magnetron sputtering (Siol et al., 2016), spin-coating (Zhou et al., 2014), close-spaced sublimation (Wen et al., 2018), aerosol assisted chemical vapour deposition (AACVD) (Khan et.al., 2018) etc. In this work, possible fabrication of  $Sb_2Se_3$  thin films by chemical molecular beam deposition (CMBD) method has been reported.

#### 2. Experimental

Polycrystalline  $Sb_2Se_3$  precursor with the stoichiometric composition was used as source materials. The preparation of  $Sb_2Se_3$  precursor as follows: Sb and Se granules (with high purity of 99.999%) was loaded into a closed quartz crucible, i.e. under vacuum. Subsequently, the quartz crucible was placed in the furnace to heat at 900 K for 8 h to synthesize  $Sb_2Se_3$  compound. Finally, quartz crucible was rapidly cooled to room temperature (RT). The crystal structure of obtained  $Sb_2Se_3$  precursor was found to be orthorhombic by X-ray diffraction (XRD) measurements.

The preparation of Sb<sub>2</sub>Se<sub>3</sub> thin films was carried out in line with the procedure described in (Razykov, 1991). The Sb<sub>2</sub>Se<sub>3</sub> precursor was loaded to the evaporator of the growth chamber and let the hydrogen flow for 10 min. in order to remove atmospheric pollutants from the

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chamber. Afterwards, the outer furnace of the chamber was turned on. When the heating level of the substrate reached the required temperature, the individual heater was turned on in order to regulate the evaporator temperature. The temperature of evaporation was set to 900 K, i.e. slightly higher than the melting point of  $\rm Sb_2Se_3$  in order to avoid the low deposition rate depicted at evaporation temperature below 885 K, whereas higher evaporation temperatures (> 950 K) yielded Se-deficient films, which will be discussed elsewhere. The substrate temperature (T\_s) was varied within the range of (670–790) K. The carrier gas, i.e. hydrogen, with different flow rates of (5–20) cm³/min was used during the deposition process. The duration of the deposition process set to 30 min. All Sb2Se3 thin films were deposited on  $(20\times20)\,\rm mm^2$  in size borosilicate glasses, which were cut into  $(10\times10)\,\rm mm^2$  pieces using a diamond saw in order to investigate their structural, morphological, electrical and optical properties.

The crystal structure Sb<sub>2</sub>Se<sub>3</sub> thin films were investigated by XRD measurements using a "Panalytical Empyrean" diffractometer (Cu Ka radiation,  $\lambda = 1.5418 \,\text{Å}$ ) with a wide-angle measurements of  $2\theta$  in the range of (10–90)° with a measurement steps of 0.01°. The experimental results were studied using the 'Joint Committee on Powder Diffraction Standard' (JCPDS, № 15-0861 for  $Sb_2Se_3$ ). Morphological and chemical composition of the samples were investigated using a scanning electron microscope (SEM-EVO MA 10) and an energy-dispersive X-ray spectroscopy (EDX, Oxford Instrument - Aztec Energy Advanced X-act SDD) at an electron acceleration voltage of 15 kV, respectively. Optical bandgap of selected Sb<sub>2</sub>Se<sub>3</sub> film was estimated from the transmission spectra obtained by spectrophotometer (HR4000, Ocian Optics). To perform electrical measurements, ohmic contacts were realized by vacuum deposition of silver on the films. The electrical conductivity of films were measured by van der Pauw method. The type of conductivity of the samples was determined by thermoelectric effect. The thickness of the films (1–2) µm was determined using micro-interferometer MII-4.

#### 3. Results and discussion

Fig. 1 shows the wide-angle  $2\theta$ - $\omega$  scans for  $Sb_2Se_3$  thin films grown in different flow rate of the hydrogen at fixed evaporation temperature of 900 K. JCPDS card of orthorhombic  $Sb_2Se_3$  has been used for matching the diffracted peaks. In general, all samples had the high background of the XRD pattern, which was argued to come from the low incident angle (Ren et al., 2015). As shown,  $Sb_2Se_3$  films grown in lower hydrogen flow rate of 5 and 7 cm²/min at lower  $T_S$  of 670 K and

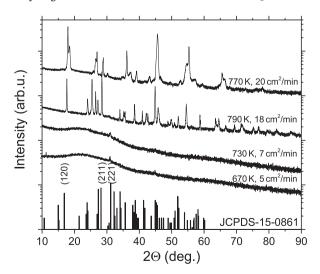


Fig. 1. Wide-angle X-ray diffraction data of  $Sb_2Se_3$  films grown in different hydrogen flow rate at indicated substrate temperatures. Note that 'Joint Committee on Powder Diffraction Standards' (JCPDS) card of orthorhombic  $Sb_2Se_3$  (15-0861) was used for the matching of the diffraction peaks.

730 K, have almost amorphous structure. Since, Sb<sub>2</sub>Se<sub>3</sub> films grown by similar method of chemical vapour deposition had polycrystalline structure at  $T_S = 670 \text{ K}$  (Razykov et al., 2017), this amorphous structure of the films may be caused by the low flow rate of the carrier gas. This is also evident from literature that amorphous structure of Sb<sub>2</sub>Se<sub>3</sub> films were mostly reported only for RT grown samples (Haque et al., 2018), whereas the crystallization of amorphous Sb<sub>2</sub>Se<sub>3</sub> thin films was reported by annealing at 448 K under vacuum and at 423 K in air (Abdel-Salam and Abdel-Wahabb, 1992). These results support our prediction that amorphous structure is mainly affected by low hydrogen flow. Although these films are almost amorphous, they exhibited small (2 2 1) peaks. Chen and co-authors reported that [2 2 1] orientation was found to be beneficial to for PV performance, as (Sb<sub>4</sub>Se<sub>6</sub>)<sub>n</sub> ribbons align perpendicular to the substrate surface (Chen et al., 2017a; Zhou et al., 2015). Hence, their Sb<sub>2</sub>Se<sub>3</sub> films with [221] orientation yielded the highest free charge carrier mobility and the highest performance compared to those with other orientation, e.g. [120] (Chen et al., 2017b). With increasing the flow rate of the transport gas, e.g.  $(18-20) \text{ cm}^2/\text{min at } T_S \text{ of } (770-790) \text{ K}, \text{ thin films grown with poly-}$ crystalline structure. Presumably, crystallization of Sb<sub>2</sub>Se<sub>3</sub> thin films was affected by high flow rate of hydrogen. Despite the disappearance of the (221) peak, these films exhibited several peaks of orthorhombic Sb<sub>2</sub>Se<sub>3</sub>, including the (211) peak (see Fig. 1). Tang and co-workers reported that Sb<sub>2</sub>Se<sub>3</sub> grains with [211] orientation could also positively contribute for enhancement of the PV performance due to the nearly perpendicular alignment of the (Sb<sub>4</sub>Se<sub>6</sub>)<sub>n</sub> ribbons (with slightly tilted angle) to the substrate surface (Zhou et al., 2015).

Fig. 2 shows the SEM images of Sb<sub>2</sub>Se<sub>3</sub> thin films grown in low (5-7) cm<sup>2</sup>/min and high (18-20) cm<sup>2</sup>/min hydrogen flow rates at different substrate temperatures. As-shown, films grown in low hydrogen flow rate exhibit smooth surface with small crystal grains on it (see Fig. 2a, b). This supports aforementioned discussion on XRD results that these films are almost amorphous with small (2 2 1) peaks. Apparently, Sb<sub>2</sub>Se<sub>3</sub> crystals are not large enough to form polycrystalline structure, yet these films depicted [221] orientation (cf. Fig. 1). This may be due to the lack of gas flow to carry molecules towards the substrate. On the other hand, films grown in high hydrogen flow rate exhibited larger grains compared to those films grown in low hydrogen flow rate (Fig. 2c, d). It is likely that the flow rate is adequate to make optimal growth condition to grow Sb<sub>2</sub>Se<sub>3</sub> crystals on the substrate, which confirms the above-mentioned XRD results that the films have polycrystalline structure. Although these films are polycrystalline, their surface morphology is dissimilar. Here not only the influence of the flow rate of the transport gas, but also effect of the substrate temperature has to be considered, since polycrystalline film grown at 770 K exhibit smoother surface in comparison to the sample grown at 790 K. Re-evaporation of Se is expected at higher substrate temperatures, which will be discussed below. EDX measurements revealed that low (high) hydrogen flow rate yielded Se enriched (Sb enriched) Sb<sub>2</sub>Se<sub>3</sub> thin films, e.g. Sb/Se ratios of about 0.24 and 1.54 were depicted for the films grown in the hydrogen flow rates of 7 cm<sup>2</sup>/min and 20 cm<sup>2</sup>/min, respectively (see Fig. 3). Low hydrogen flow rate was not sufficient to carry out enough Sb-Se atoms to make Sb<sub>2</sub>Se<sub>3</sub> thin films with stoichiometric composition, hence Se-rich condition could be the reason for the film growth with amorphous nature with smooth surface. Appearance of (221) peak in this film can be explained with chemical bond approach (Shaaban et al., 2007) as follows: different kinds of atoms (Sb-Se) combine more favourably in comparison to the same kind (Sb-Sb or Se-Se). This might be the reason for the appearance of [221] orientation in Sb<sub>2</sub>Se<sub>3</sub> films grown in the low hydrogen flow rate although these films had low Sb content. With increasing hydrogen flow rate, the samples grown with higher Sb content (see Fig. 3b), where the probability of Sb-Se bonds increases in Sb<sub>2</sub>Se<sub>3</sub> film. Consequently, Sb<sub>2</sub>Se<sub>3</sub> film tends to grow with polycrystalline structure, which is apparent from XRD data and SEM images. This supports our prediction that optimized hydrogen flow rate is needed to grow Sb<sub>2</sub>Se<sub>3</sub> thin films with

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